AMENDMENTS TO THE CLAIMS PURSUANT TO 37 CFR § 1.21

- 1. (Presently Amended) A device comprising i) a first microchannel and ii) a second microchannel, said first and second microchannels etched in a substrate so as to be intersecting, and iii) a meltable material disposed within a substrate said first microchannel and associated with iv) a heating element associated with said meltable material.
- 2. (Canceled)



- 3. (Original) The device of Claim 1, wherein said substrate is selected from the group consisting of glass and silicon.
- 4. (Original) The device of Claim 1, wherein said meltable material comprises solder.
- 5. (Original) The device of Claim 1, wherein said solder comprises a eutectic alloy of tin and lead.
- 6. (Original) The device of Claim 5, wherein said alloy comprises 60:40 Sn:Pb.
- 7. (Original) The device of Claim 4, wherein said solder comprises 40:60 Sn:Pb.
- 8. (Original) The device of Claim 1, wherein said meltable material is selected from a group consisting of plastic, polymer and wax.
- 9. (Original) The device of Claim 1, further comprising a diaphragm positioned such that it is capable of touching said meltable material when extended.

- 10. (Presently Amended) A method, comprising:
 - a) providing a device comprising <u>i) a first microchannel and ii) a second</u>
 microchannel, said first and second microchannels etched in a substrate so as to be
 intersecting, iii) a meltable material disposed within a substrate said first microchannel,
 said meltable material associated with a heating element; and
 - b) heating said meltable material with said heating element such that said meltable material at least partially liquifies to create a liquified material and such that said substrate is not damaged, wherein said liquified material moves into said second microchannel.
- 11. (Original) The method of Claim 10, further comprising c) allowing said meltable material to cool.
- 12. (Canceled)
- 13. (Original) The method of Claim 10, wherein said substrate is selected from the group consisting of silicon and glass.
- 14. (Original) The method of Claim 10, wherein said meltable material comprises solder.
- 15. (Original) The method of Claim 14, wherein said solder comprises a eutectic alloy of tin and lead.
- 16. (Original) The method of Claim 15, wherein said alloy comprises 40:60 Sn:Pb.
- 17. (Original) The method of Claim 10, wherein said meltable material is selected from a group consisting of plastic, polymer and wax.
- 18 21. (Canceled)